OxyCycler C42
Dynamic O₂ and CO₂ Subchamber Controller

Two Chamber Dynamic 0.1-99.9% O₂ and 0.1-20.0% CO₂

- Highly reproducible O₂/CO₂ exposures
- Dynamic O₂/CO₂ control
- Limitless protocol possibilities
- Physiological O₂/CO₂ simulation
- Pathologic O₂/CO₂ modeling
- Accountability
- Automated control
- PC interface

DUAL CHAMBER / DUAL GAS
The OxyCycler C42 is a unique dual channel/dual gas controller for incubators and C-Chambers. Oxygen and carbon dioxide control is managed via independently programmable channels for optimum control. No other instrument has such a fine simulation of dynamic exposure. Applications include intermittent hypoxia, graded hypoxia, and timed hyperoxia.

OXYGEN CONCENTRATION
Changes in O₂ concentration do affect the physiology of the cells in vivo and now you can simulate these O₂ dynamics in vitro. Complex, multi-setpoint oxygen profiles can be arranged to recreate conditions such as heart attack, strokes and epilepsy. When a profile is made, it can be reproduced to develop these dynamic models. The OxyCycler C42 is the predominant instrument capable of meeting these demands.

CREATE ANY PROFILE
The OxyCycler C42 controller is a unique instrument that offers sophisticated O₂ and CO₂ profiling. It easily creates any profile needed between 0.1-99.9% O₂ and 0.1-20.0% CO₂ independently and in multiple chambers simultaneously. The OxyCycler C42 enables multiple setpoints for any length of time, over any rate of change between these setpoints with any number of cycles and setpoints. The OxyCycler C42 makes complex oxygen cycling easy.

MANY FEATURES
A standard OxyCycler C42 comes with computer software for easy interface, real time trend charting, data logging, and remote operation. Since the OxyCycler C42 works with semi-sealed subchambers the profiles are normobaric. N₂ and O₂ gas infusions displace the chamber gas while internal and external pressure remain equilibrated.

Control remotely. Monitor without disturbing cells.
Installation
1. Set OxyCycler C42 on or near host chamber and plug it in.
2. Hook up sensor and gas infusion tube and insert both into the chamber.
3. Hook up gas supply.

Operation
OPERATION IS SIMPLE
Cells are dynamic entities and the OxyCycler C42 is the first controller to provide dynamic O₂ and CO₂ to keep up with the needs of cells. Dynamic exposures are programmed with a series of setpoints that can change, be stored and re-run with the click of a mouse.

Gas
USE ANY GAS SUPPLY
OxyCycler C42 conveniently utilizes gas from any source. Best supply depends on consumption. Compressed gas is best in low consumption applications. Generator is best in high consumption applications. Liquid is best in between.

SAVES GAS AND MONEY
Chamber gas consumption varies widely, but in every case the OxyCycler C42 always and absolutely minimizes gas consumption. It’s maximally efficient! Gas costs are reduced to absolute minimum.

How It Works
The OxyCycler C42 is used predominantly as a dual subchamber system for experiment and control. These isolating subchambers are placed within a third party CO₂ (only) or thermal incubator. The OxyCycler C42 is supplied by three control gases: O₂, N₂, and CO₂ and fits any of our standard subchambers. The OxyCycler C42 connects to the subchamber by flexible umbilicals, which consist of electrical and pneumatic leads, that are inserted into the incubator.

The pod component of the OxyCycler C42 is uniquely designed to isolate the critical cell environment which can get contaminated from the sensing mechanisms for monitoring the gases in the chamber. This isolation is accomplished by putting the sensors inside the pod and pumping a sample from the chamber to the pod, then past the sensors back into the chamber. This side stream sampling starts with the sterile filter and ends with a sterile filter, minimizing the chance of chamber contaminating the sensor loop. Likewise, if there ever was a contamination in the sensor loop it wouldn’t contaminate the chamber.
The OxyCycler C42 allows you to create any change in oxygen and carbon dioxide concentration. You can independently control and profile up to two chambers simultaneously, which means you have one control profile and one experimental profile.

Up to seventeen different profiles can be stored and each can be run in any chamber at any time. Chambers can have the same profile simultaneously or can be staggered to begin at different times. Each profile can have 1 to 20 setpoints and can be from 0.1-99.9% O₂ and 0.1-20.0% CO₂. The rate between setpoints can be 0-999 minutes with resolution to seconds. Profiles can be cycled continuously or 1 to 99 times.

The OxyCycler C42 is an entry level subchamber controller for dynamic control at programmable setpoints. The importance of a second chamber is based upon the lack of proven dynamic profiles. The second chamber provides a control for stepwise comparison between the best profile to date and your new profile. Optimize your process, perfect your cell response.

Hypoxic stress can model components of many severe diseases such as heart attacks, strokes, asthma, or epilepsy. Frequency, duration and degree of drops are all adjustable.

Cells destined for implantation will experience hypoxia and may be better prepared if they are conditioned to it before implantation. Ischemia may also be protected by conditioning. The OxyCycler C42 can easily run any preconditioning profile.

Model step reduction in oxygen, similar to altitude acclimation, to gradually condition cells for hypoxic upregulation of gene expression. The rate of change between any two levels is adjustable and repeatable. The duration at any given level is adjustable and repeatable.

Sudden increases in oxygen can cause cell damage. The OxyCycler C42 allows modeling toxicity of oxygen in any cell culture, similar to toxicity from recreational oxygen inhalation by athletes, therapeutic oxygen administration in critical care units, and other sudden exposures to high oxygen. The rate of oxygen increase can be adjusted to change faster to overwhelm antioxidants, or change slower to condition for antioxidants.
**Front Panel**

1. **Controller**: Bright digits display process values and provides manual user interface to control gas infusion.
2. **Bleed Valves and Barbs**: Bleeds gases out of gas supply lines. Calibration cup for sensor attaches here.
3. **ZERO Calibration Gas Flowmeter**: Used for calibration.
4. **SPAN Calibration Gas Flowmeter**: Used for calibration.
5. **Needle Valves for Chamber 1**: Sets infusion rate of control gases in each chamber to accommodate different dynamics. Can manually override controller to shut off gas.
6. **Needle Valves for Chamber 2**: Sets infusion rate of control gases in each chamber to accommodate different dynamics. Can manually override controller to shut off gas.

**Back Panel**

7. **Accessory Receptacle**: 10 Pin Receptacle is for connecting optional accessory units.
8. **Communications Cables**: These cables relay information for the sensors and gives power to the sample draw pump.
9. **Alarm Receptacle**: Connect an appropriate alarm to this jack.
10. **RS485 Communications Cables**: One cable attaches to a computer and the other cable attaches to another unit, to allow communication with the computer (if applicable).
11. **Umbilicals**: Delivers infusion and calibration gas from the unit to the chamber. To connect, push the connector onto the receptacle.
12. **Supply Gas Hose Barbs**: Barbs for 1/4 inch I.D. hose from gas sources. Handles pressure up to 40 PSIG.
13. **Ground Stud**: For grounding the unit to protect from electric damage.
14. **Power Receptacle**: 12VDC power supply connects here.